10/560581 CT/PT0 12 DE0 2000

IAP9 Rec'd PCT/PTO sl.3 DEC 2005

Form PTO-1449 (REV. 8-83)	00 2 4pti 01 001111111110			ATTY DOCKET NO. 126274			APPLICATION NO. New National Stage Patent Application of		
INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)					,			P2004/007	350
				APPLICANTS Masahiro SAKURADA et al.					
				LING DATE					
	·	U.S.	PATENT	DOCUMEN	ITS				
EXAMINER INITIAL		DOCUMENT NUMBER		DATE 1		NAME		CLASS	SUB CLASS
	<u> </u>		ļ						
	-					·			
		·							
			<u> </u>		-				
<u>-</u>	<u> </u>	FOREIG	ON PATE	NT DOCUM	IENTS				
		DOCUMENT NUMBER	DA			OUNTRY		CLASS	SUB CLASS
FH.	1	JP A 2003-002786 w/abst. & trans	01/08/2	003 JA	PAN				7
KH,	2	JP A 08-268794 w/abst. & trans	10/15/1	996 JAI	PAN			_	-
KH.	3	JP A 08-330316 w/abst. & trans	12/13/1	996 JAI	PAN			_	
БH	4	JP A 2000-063196 w/abst. & trans	02/29/2	000 JA1	PAN			-	
FH	5	JP A 2000-313691 w/abst. & trans	11/14/2	000 JAI	PAN				_
F#.	6	JP A 2002-338389 w/abst. & trans	11/27/2	002 JAI	PAN			_	•
FH.	7	JP A 11-147786 w/abst. & trans	06/02/1	999 JAI	PAN				
		OTHER DOCUMENTS (In	cluding A	uthor, Title,	Date, Pertine	nt Pages, etc.)			
БH	8	V. V. Voronkov, "The mechanism of	on in Silicon,	' Journal of Crysta	l Growt	h, 59 (1982	2), 625-643.		
БН.									
		9, pp. 1849-1871, 1990.							
	<u> </u>					•	,		
	ļ								
EXAMINER	J	a sollate			DATE CONSIDERED				

Date: December 13, 2005

A